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# Organic Functionalization of Germanium Nanowires using Arenediazonium Salts

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## Abstract

The formation of organic functionalization layers on germanium (Ge) nanowires was investigated using a new synthetic protocol employing arenediazonium salts. Oxide-free, H-terminated Ge nanowires were immersed in diazonium salt/acetonitrile solutions and the molecular interface of the functionalized nanowires was analyzed by reflectance infrared spectroscopy and X-ray photoelectron spectroscopy. The morphology of the modified nanowires was investigated by electron microscopy. Surface functionalization of the nanowires was found to be slow at room temperature, but proceeded efficiently with moderate heating (50 °C). The use of arenediazonium salts can result in the formation of aryl multilayers, however the thickness and uniformity of the organic layer was found to be

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2  
3 strongly influenced by the nature of the substituents on the aromatic ring. Substituents  
4 attached to the 3-, 4- and 5- ring positions hindered the formation of multilayers, while the  
5 presence of sterically bulky ring substituents affected the homogeneity of the organic layers.  
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8 We successfully demonstrate that arenediazonium salts are very flexible precursors for  
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10 nanowire functionalization, with the possibility to covalently attach a wide variety of  
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12 aromatic ligands, offering the potential to alter the thickness of the resulting outer organic  
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## 22 Introduction

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25 Nanowires exhibit extremely large surface-to-volume ratios and consequently surface  
26 reactivity plays an important role in determining their chemical and electrical properties. The  
27 germanium (Ge)/GeO<sub>x</sub> interface is characterized by a high density of surface defects and Ge  
28 displays far more complex oxidation chemistry<sup>1-2</sup>. Unlike Si, which possesses one stable  
29 oxide (SiO<sub>2</sub>), Ge forms oxides in the 2+ (GeO) and 4+ (GeO<sub>2</sub>) oxidation states. Schmeisser  
30 *et al.*<sup>3</sup> carried out synchrotron studies on planar Ge surfaces and reported the presence of all  
31 four oxidation states. The composition of the surface oxide is strongly dependent on the  
32 oxidative environment, for example, dry oxidation favors the formation of Ge<sup>2+</sup>, while the  
33 presence of water vapor gives rise to the formation of higher Ge oxidation states<sup>4</sup>.  
34  
35 Furthermore, oxidation of the Ge surface is greatly accelerated by exposure to UV light,  
36 producing predominately GeO<sub>4</sub><sup>5</sup>. Surface oxides are typically removed by treatment with  
37 aqueous HF, producing a hydrogen-terminated surface but the stability of the H-passivation  
38 layer under ambient conditions is limited to a few minutes before re-oxidation of the surface  
39 starts to occur<sup>6-8</sup>. GeO<sub>x</sub> can also be removed by treatment with the other halogenic acids -  
40 HCl, HBr and HI, yielding oxide free surfaces passivated by the corresponding halogen  
41 species<sup>9-10</sup>.  
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3 Cullen and co-workers<sup>11</sup> first reported organic functionalization of Ge in 1962 when they  
4 demonstrated the attachment of ethyl groups via Grignard reagents to Cl-terminated Ge  
5 surfaces. Wet organic functionalization of Ge has been limited to the attachment of relatively  
6 simple ligands including alkanes<sup>11-17</sup>, alkenes<sup>18-19</sup> and alkanethiols<sup>19-24</sup>. There are a number  
7 of drawbacks associated with many of the methodologies utilized for the surface  
8 functionalization of Ge, for example hydrogermylation reactions require relatively high  
9 reaction temperatures ( $> 200\text{ }^{\circ}\text{C}$ )<sup>18</sup>, alkyl Grignard reagents often require long reaction times  
10 (6 h - 8 days)<sup>25</sup>. Furthermore, the reactive nature of Grignard reagents makes them  
11 incompatible with organic functionalities containing acidic protons (alcohols, carboxylic  
12 acids, amines), thereby limiting their use to relatively simple aliphatic ligands. The ability to  
13 introduce a range of chemical functionalities is essential for the integration of nanowires for  
14 electrical, chemical and biological applications. One strategy that has proved effective for  
15 the functionalization of several surfaces is the use of arenediazonium salts. Arenediazonium  
16 salts can be easily synthesized from their corresponding amines, from which there are a huge  
17 range of diverse and commercially available precursors. Attachment of organic ligands by  
18 electrochemical reduction of diazonium salts is well established on carbon<sup>26-28</sup>, metal<sup>29-30</sup>, and  
19 oxide<sup>31-32</sup> surfaces. Covalent grafting of ligands can also be initiated by chemical reduction  
20 with hypophosphorous acid<sup>33</sup> and metal catalysts<sup>34</sup>. There have also been reports of  
21 spontaneous attachment of aromatic ligands onto carbon<sup>35-37</sup>, metal<sup>38-42</sup> and semiconductor  
22 surfaces<sup>43-46</sup>, making diazonium salts a promising functionalization approach.

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54 He *et al.*<sup>47-48</sup> demonstrated that the electronic properties of planar Si could be altered by  
55 attaching organic molecules with different electron donating abilities. Tailoring the transport  
56 properties via surface functionalization is highly advantageous for Ge nanowires, where the  
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3 use of conventional dopants, such as diborane, is known to negatively affect the nanowire  
4 morphology<sup>49</sup>.  
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8 As far as we are aware, the reactivity of arenediazonium salts towards Ge surfaces has not  
9 been reported in the literature. Furthermore, there has been little investigation into how the  
10 presence of ring substituents influence the formation of the chemical grafted functionalization  
11 layer. In this paper we report the covalent attachment of organic ligands, via arenediazonium  
12 salts, onto H-terminated Ge nanowire surfaces. XPS and attenuated total reflectance infrared  
13 (ATR-IR) spectroscopy were utilized to probe the organic ligands, derived from  
14 arenediazonium salts, at the nanowire surfaces. The morphology of the functionalized  
15 nanowires was investigated by scanning electron microscopy (SEM) and transmission  
16 electron microscopy (TEM). We also explore the effects of the aromatic ring substituents on  
17 the structure and uniformity of the functionalization layer.  
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## 36 **Experimental**

### 37 *Ge Nanowire Synthesis*

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39 Gold-seeded Ge nanowires were synthesized on Si substrates by the thermal decomposition  
40 of diphenyl germane (purchased from ABCR) in supercritical toluene at a temperature of 400  
41 °C and a pressure of 24.1 MPa. Details of the experimental set-up are described elsewhere<sup>50</sup>.  
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44 After synthesis, the nanowires were rinsed with chloroform, hexane and isopropyl alcohol  
45 (IPA) and dried under Ar. The nanowires had diameters ranging from 20-120 nm, with a  
46 mean diameter of ~80 nm and displayed a predominate (111) growth direction with (110) and  
47 (112) growth directions also present. The nanowires examined were mostly cylindrical in  
48 nature, however a significant proportion of the (111) and (110)-oriented nanowires exhibited  
49 hexagonal cross sections displaying {110}, {111} and {100} surface facets<sup>13, 51-52</sup>.  
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### *General Procedure for the Diazotization of Anilines*

The arenediazonium tetrafluoroborate salts were synthesized from the corresponding anilines according to literature procedures<sup>44</sup>. All glassware was cleaned with aqua regia, dried overnight in an oven at 180 °C and allowed to cool down under a N<sub>2</sub> atmosphere. Diethyl ether (Et<sub>2</sub>O) was distilled from sodium/benzophenone. Acetonitrile (MeCN) was distilled from calcium hydride onto freshly prepared molecular sieves (3 Å). Anhydrous methanol (MeOH) was purchased from Sigma-Aldrich. In a glovebox, nitrosonium tetrafluoroborate (NOBF<sub>4</sub>, purchased from ABCR) (1.1 molar equivalents per aniline) was added to a Schlenk flask and sealed with a rubber septum. A minimum amount of anhydrous MeCN was added to dissolve the salt and the solution was cooled to -30 °C using a *p*-xylene-liquid N<sub>2</sub> cooling bath. Separately, the aniline was added to a 2-neck round bottom flask and degassed with N<sub>2</sub> for 30 min. A minimum amount of MeCN was added to dissolve the aniline and the solution was cooled to 0 °C. The organic solution was transferred to the salt solution dropwise via a cannula. After the addition, the solution was left at -30 °C for ~30 min. The temperature was raised to 0 °C and anhydrous Et<sub>2</sub>O was added slowly until the product precipitated out of solution. The product was collected by filtration and washed with anhydrous Et<sub>2</sub>O (× 3). The arenediazonium salts displayed good stability in air but decomposed on exposure to light. The salts were wrapped in alumina foil to prevent photochemical decomposition and stored in a freezer (-20 °C). Prior to the nanowire functionalization reactions the diazonium salts were re-crystallized from cold anhydrous Et<sub>2</sub>O.

### *Synthesis of 3,4,5-Trifluorophenyl Diazonium Tetrafluoroborate*

150 mg (0.6 mmol) of 3,4,5-trifluoroaniline was dissolved in 1 ml of MeCN and converted to its benzenediazonium (BD) salt following the general procedure previously described to give

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3 a very pale yellow solid in a 89 % yield. IR (KBr): 2324 cm<sup>-1</sup> ( $\nu_{\text{N=N}}$ ), 1617 cm<sup>-1</sup>, 1411 cm<sup>-1</sup>  
4  
5 ( $\nu_{\text{C=C}}$ ), 1220 cm<sup>-1</sup> ( $\nu_{\text{CF}}$ ). H<sup>1</sup> NMR (400 MHz, CDCl<sub>3</sub>):  $\delta$  8.42 (d, 2H).  
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#### 10 11 *Synthesis of (Heptadecafluorooctyl)phenyl Diazonium Tetrafluoroborate*

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13 200 mg (0.4 mmol) of heptadecafluorooctyl aniline was dissolved in 2 ml of MeCN and  
14  
15 sonicated briefly. The aniline was converted into the corresponding BD salt by the procedure  
16  
17 described to afford a colourless solid with a 76 % yield. IR (KBr): 2320 cm<sup>-1</sup> ( $\nu_{\text{N=N}}$ ), 1415  
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19 cm<sup>-1</sup> ( $\nu_{\text{C=C}}$ ), 1150-1240 cm<sup>-1</sup> ( $\nu_{\text{CF}}$ ). H<sup>1</sup> NMR (400 MHz, CDCl<sub>3</sub>): 8.42 (dd, 2H) 7.73 (dd, 2H).  
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#### 28 *Synthesis of 4-Nitrobiphenyldiazonium Tetrafluoroborate*

29  
30 100 mg (0.46 mmol) of 3,4-amino-4'-nitrobiphenyl was dissolved in ~ 5ml of MeCN,  
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32 sonication was required to completely dissolve the aniline, which was converted to the  
33  
34 corresponding BD salt according to the general procedure described to give an very pale  
35  
36 yellow coloured solid with a 67 % yield. IR (KBr) 2355 cm<sup>-1</sup>, 2270 cm<sup>-1</sup> ( $\nu_{\text{N=N}}$ ), 1518 cm<sup>-1</sup>  
37  
38 as( $\nu_{\text{N-O}}$ ) 1350 cm<sup>-1</sup> s( $\nu_{\text{N-O}}$ ), 1580 cm<sup>-1</sup> ( $\nu_{\text{C=C}}$ ), 3068 cm<sup>-1</sup> ( $\nu_{\text{C-H}}$ ). H<sup>1</sup> NMR (400 MHz, CDCl<sub>3</sub>):  
39  
40  $\delta$  7.72 (m,  $J = 8.5, 4.7, 1.4$  Hz, 2H), 7.85 (m,  $J = 8.5, 4.7, 1.4$  Hz, 2H), 8.05 (dd,  $J = 8.8, 4.8$   
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42 Hz, 2H), 8.51 (dd, 2H).  
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#### 51 *General Procedure for Ge Nanowire Functionalization using Arenediazonium Salts*

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53 Ge nanowires were functionalized on the Si substrates from which they were grown and later  
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55 removed for analysis. The native Ge oxide was first removed by immersing the nanowires  
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57 into 5 % aqueous HF solution for 5 min. The nanowires were then rinsed with deionized  
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59 water, dried with Ar and transferred into a N<sub>2</sub> glovebox (< 1 ppm O<sub>2</sub>). The nanowires were  
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3 immersed in freshly prepared diazonium salt solutions (1-5 mM) in anhydrous de-oxygenated  
4 MeCN. Functionalization reactions were carried out at room temperature in a glove box, or  
5  
6 MeCN. Functionalization reactions were carried out at room temperature in a glove box, or  
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8 at 50 °C on a Schlenk line under a N<sub>2</sub> atmosphere. Reaction times ranging from 0.5, 2, 12  
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10 and 24 h were used. During the functionalization procedure the nanowires were protected  
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12 from exposure to light by alumina foil to avoid the possibility of photochemical  
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14 decomposition, as diazonium salts are known to be light sensitive. However, no differences  
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16 in the XPS and IR spectra were observed when the reaction apparatus was not protected from  
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18 light. After functionalization the nanowires were immersed in MeCN, soaked for 5 min and  
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20 then rinsed with more MeCN. This soaking/rinsing procedure was repeated three times to  
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22 remove unreacted or physisorbed products. The nanowires were then washed with anhydrous  
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24 MeOH followed by drying under a stream of N<sub>2</sub>.  
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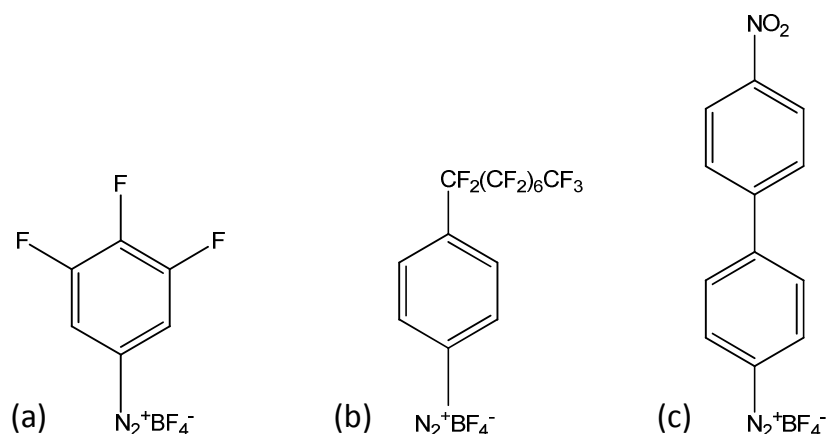
### 33 *Materials Characterization*

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35 Scanning electron microscopy (SEM) images were acquired on a FEI Inspect F, operating at  
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37 5 kV accelerating voltage. Transmission electron microscopy (TEM) images were acquired  
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39 on a Jeol 2100 operating at voltage 200 kV accelerating voltage. X-ray photoelectron  
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41 spectroscopy (XPS) analysis was conducted on a VSW Atom tech System with a twin anode  
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43 X-ray source (Al/Mg). Survey spectra were captured at a pass energy of 100 eV, a step size  
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45 of 0.7 eV and a dwell time of 0.1 ms. The core level spectra were an average of 15 scans  
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47 captured at a pass energy of 50 eV, a step size of 0.2 eV and a dwell time of 0.1 ms. **The**  
48  
49 **spectra were corrected for charge shift by reference to C 1s line at a binding energy of 284.8**  
50  
51 **eV.** The photoemission data was processed using a Shirley background correction and peaks  
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53 were fit to Voigt profiles. The **Ge 3d signals were fit to two peaks with a spin-orbit coupling**  
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55 **of 0.585 eV and an intensity ratio of 3:2, corresponding to the Ge 3d<sub>5/2</sub> and Ge 3d<sub>3/2</sub> at**  
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57 **binding energies of 28.9 and 29.5 eV (fwhm 1.5 eV), respectively.** Attenuated total  
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3 reflectance Fourier transfer Infrared (ATR-FTIR) analysis was carried out using a  
4 PerkinElmer spectrum 100 fitted with an ATR attachment containing a ZnSe crystal. The  
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6 spectra were averaged over 10 scans at a resolution of  $2\text{ cm}^{-1}$ . For the analysis, the nanowires  
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8 were removed from the Si substrate and transferred to the ATR crystal.  
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13 Figure 1 illustrates the various diazonium salts that were investigated for surface  
14 functionalization of Ge nanowires: (a) 3,4,5-trifluorobenzenediazonium tetrafluoroborate ( $\text{F}_3$ -  
15 BD), (b) heptadecafluorooctyl benzenediazonium tetrafluoroborate ( $\text{F}_{17}\text{C}_8$ -BD) and (c)  
16 nitrobiphenyldiazonium tetrafluoroborate ( $\text{NO}_2\text{Ph}$ -BD). Fluorine substituents make excellent  
17 analytical reporting groups for XPS, having high photoionization cross sections, as well as  
18 exhibiting strong and characteristic IR absorbances. Similarly, nitro groups display strong IR  
19 vibrations and the XPS binding energy of the nitrophenyl group is easily distinguished from  
20 other N-containing functionalities. As well as ease of identification, the nature of the ring  
21 substituents of each diazonium salt differs considerably, for example  $\text{F}_{17}\text{C}_8$ -BD contains an  
22 electron withdrawing group (EWG), while  $\text{F}_3$ -BD displays electron donating mesomeric  
23 effects and electron withdrawing inductive effects. These properties are significant as EWGs  
24 are known to influence the ease of reduction of the diazonium group, and consequently may  
25 affect reactivity towards the Ge surface<sup>53</sup>. Additionally, other factors influencing nanowire  
26 functionalization such as the location of the ring substituents and steric effects of the  
27 diazonium salts are compared.  
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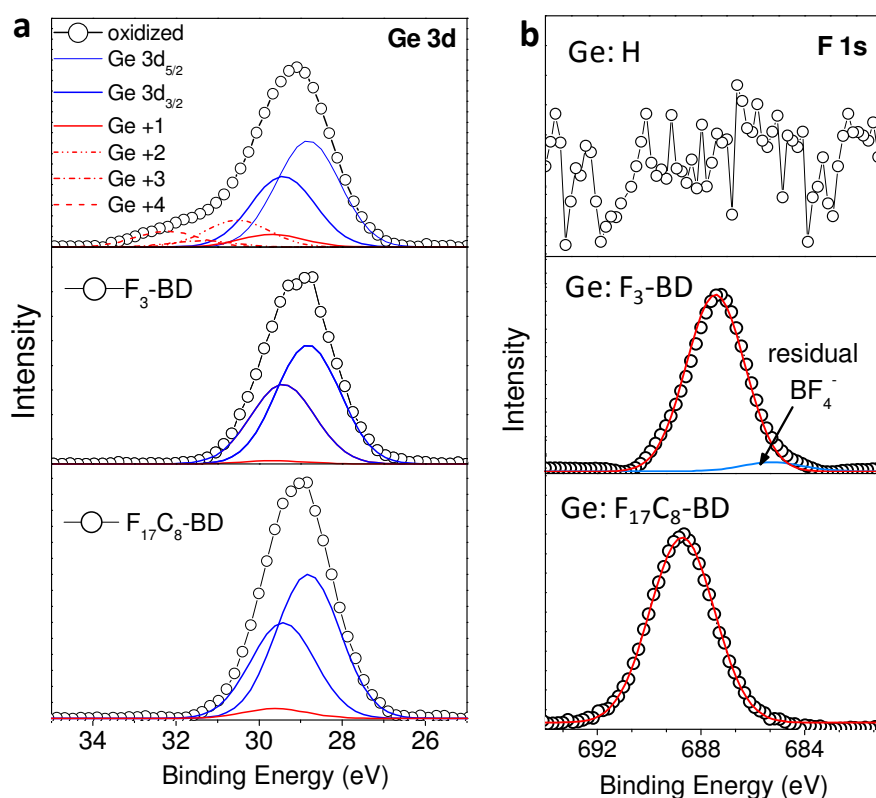


**Figure 1.** Structures of arenediazonium salts investigated for Ge nanowire functionalization: (a) 3,4,5-trifluorobenzenediazonium ( $F_3$ -BD), (b) heptadecafluorooctyl benzenediazonium tetrafluoroborate ( $F_{17}C_8$ -BD) and (c) nitrophenyldiazonium tetrafluoroborate ( $NO_2$ Ph-BD).

## Results and Discussion

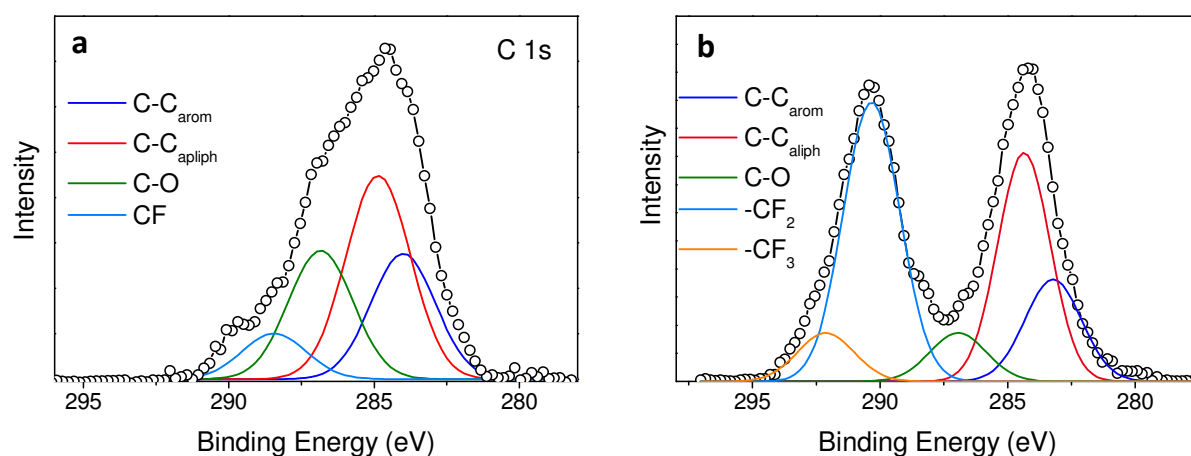
Figure 2(a)(i) displays the Ge 3d core level spectrum of untreated Ge nanowires exposed to air for 12 h after synthesis. The Ge  $3d_{5/2}$  and Ge  $3d_{3/2}$  doublet peaks are located at binding energies of 28.9 and 29.5 eV, respectively, as well as four chemically shifted peaks located at higher binding energies which are associated with the four oxidation states of  $Ge^3$ . Figure 2(a)(ii) and (iii) displays Ge 3d XPS data of H-terminated Ge nanowires after reaction with compounds  $F_{17}C_8$ -BD and  $F_3$ -BD at 50 °C for 6 h. The spectra of the functionalized Ge nanowires treated with the diazonium salt solutions were predominately oxide free, but trace amounts of  $Ge^{+1}$  were present. To identify if the oxide peak is associated with the functionalization procedure or originating from post-functionalisation oxidation, Ge nanowires functionalized with  $F_3$ -BD were exposed to ambient conditions for 6 h before carrying out XPS analysis. The air protected and ambient exposed samples contained similar amounts of  $Ge^{+1}$  oxide as determined by the  $Ge3d:Ge^{+1}$  XPS peak intensity (see Supporting

Information, figure S1), indicating that the oxide is most likely stemming from the HF treatment<sup>8</sup>. Functionalization is also accompanied by the appearance of the F *1s* peak in the XPS data, as shown figure 2(b). Nanowires modified with F<sub>3</sub>-BD show the F *1s* peak centred at a binding energy of 688 eV, typical of aromatic fluorocarbons (=C-F)<sup>54</sup>. For nanowires treated with F<sub>17</sub>C<sub>8</sub>-BD, the F *1s* peak is located at a higher binding energy of 689 eV, consistent with the presence of aliphatic fluorocarbon chains (-CF<sub>2</sub>)<sup>55</sup>. There was no or only trace amounts of inorganic fluorides, *i.e.* BF<sub>4</sub><sup>-</sup>, present at a binding energy of 685 eV, suggesting that the BF<sub>4</sub><sup>-</sup> group is no longer associated with the ligand.



**Figure 2.** (a) Ge *3d* XPS core level spectra of the oxidized and functionalized Ge nanowires and (b) the F *1s* XPS core level spectra of H-terminated Ge nanowires and after reaction with arenediazonium salts.

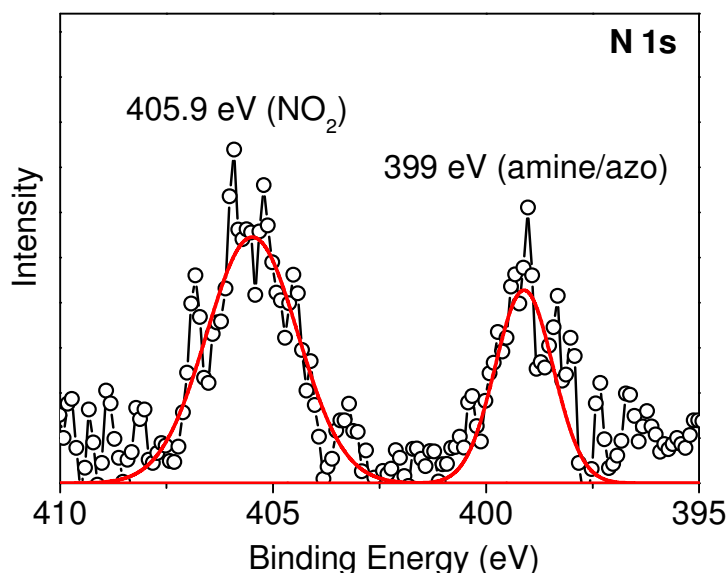
The presence of organic ligands is also indicated by the C *1s* XPS core level spectra, as shown in figure 3. Fluorocarbons induce a large chemical shift in the C *1s* spectra which can be seen in figure 3 at binding energies of 288.6 eV (=C-F), 290.3 eV (-CF<sub>2</sub>) and 292.3 eV (-CF<sub>3</sub>)<sup>56</sup>. The presence of an aliphatic carbon signal at 284.6 eV, most likely originates from adventitious carbon contamination and residual carbon species from the nanowire synthesis and the functionalization reactions. Similarly, the C-O signal possibly originates from solvents used in the reaction synthesis or the functionalization procedure such as IPA, or due to hydrocarbons physisorbed on top of the functionalization layer<sup>25</sup>.



**Figure 3.** C *1s* XPS core level spectra of Ge nanowires functionalized with (a) F<sub>3</sub>-BD and (b) F<sub>17</sub>C<sub>8</sub>-BD.

Figure 4 illustrates an N *1s* XPS core level spectrum of Ge nanowires after reaction with NO<sub>2</sub>Ph-BD at 50 °C. The appearance of two peaks in the N *1s* spectrum is well reported in the literature for surfaces functionalized with nitrophenyl-containing compounds<sup>28, 34, 57</sup>. The peak located at a binding energy of 405.9 eV is characteristic of the NO<sub>2</sub> group, while the second peak located at a lower binding energy of 399 eV corresponds to a reduced form of

nitrogen. Several groups have attributed the latter peak to the reduction of the  $\text{NO}_2$  group to amines ( $-\text{NH}_2$ ) under the XPS beam<sup>41,58</sup>. Lud and co-workers<sup>59</sup> found that the intensity of the peak increased with exposure to X-ray irradiation. A decrease in the  $\text{NO}_2$  group peak intensity was observed after several XPS scans indicating that irradiation induced reduction plays a role in the presence of the peak at 399 eV. However, studies have also associated the peak at  $\sim 400$  eV to the presence of azo ( $\text{N}=\text{N}$ ) or azoxy ( $\text{N}=\text{N}-\text{O}$ ) species, which are incorporated into the functionalization layer during the reaction<sup>28, 60-61</sup>. Importantly, the absence of a peak associated with the diazonium group ( $\text{N}\equiv\text{N}^+$ ) at  $\sim 402$  eV<sup>62</sup>, suggests that the salt has reacted with the Ge surface.



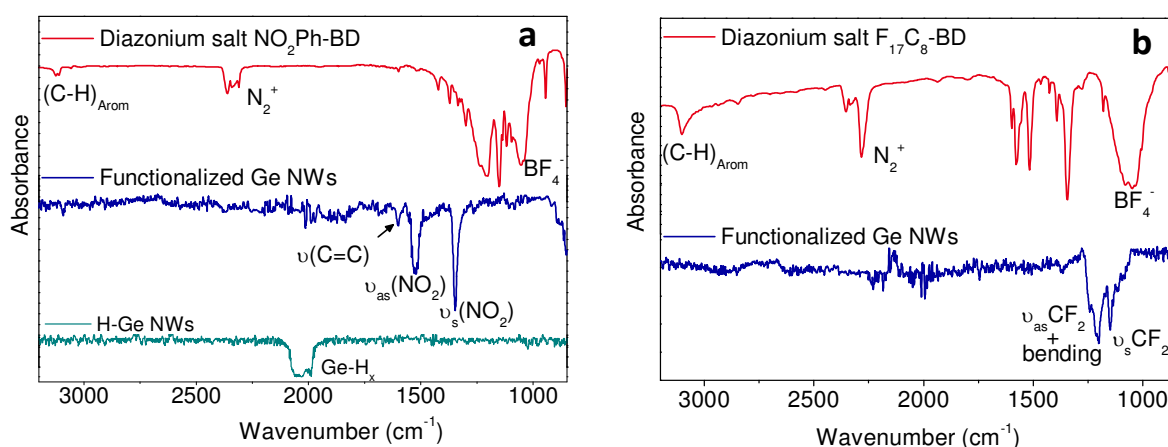
**Figure 4.** N  $1s$  XPS core level spectrum of H-terminated Ge nanowires functionalized with  $\text{NO}_2\text{Ph-BD}$ .

#### *FTIR Analysis of Functionalized Ge Surfaces*

Figure 5 compares the IR spectra of the bulk arenediazonium salts and the ATR-IR spectra after reaction with H-terminated Ge nanowires, at 50 °C. The IR spectra of H-terminated Ge nanowires, shown in figure 5(a) consists of a broad vibrational stretch located at  $\sim 2050$   $\text{cm}^{-1}$ ,

which corresponds to the presence of mono-, di- and trihydride species<sup>13, 18</sup>. The Ge nanowire spectra display several structural features associated with the passivating ligands. Figure 5(a) illustrates the spectra of Ge nanowires treated with NO<sub>2</sub>Ph-BD. The symmetric ( $\nu_s$ ) and asymmetric ( $\nu_{as}$ ) NO<sub>2</sub> stretches are observed at 1346 cm<sup>-1</sup> and 1522 cm<sup>-1</sup>, respectively<sup>63</sup>. The C=C stretching vibration is also observed at 1597 cm<sup>-1</sup>. Notably, there is a disappearance of the vibrational band at 2250 cm<sup>-1</sup>, characteristic of the N<sub>2</sub><sup>+</sup> group and the absence of the strong broad absorption peak for BF<sub>4</sub><sup>-</sup>, located at ~1050 cm<sup>-1</sup><sup>41</sup>. The absence of these features is consistent with the XPS analysis and suggests the diazonium salt moiety (N<sub>2</sub><sup>+</sup>BF<sub>4</sub><sup>-</sup>) is no longer associated with the ligands.

Figure 5(b) displays the ATR-IR spectra of F<sub>17</sub>C<sub>8</sub>-BD salt and functionalized Ge nanowires. The spectral signature of the C-F bonds can be observed in the region ranging from 1100-1300 cm<sup>-1</sup>. The CF<sub>2</sub> symmetric ( $\nu_s$ CF<sub>2</sub>) and asymmetric ( $\nu_{as}$ CF<sub>2</sub>) stretching vibrations occur at 1150 cm<sup>-1</sup> and 1240 cm<sup>-1</sup> respectively, as well as the bending modes ( $\delta$ (CC)) at 1206 cm<sup>-1</sup><sup>64</sup>.

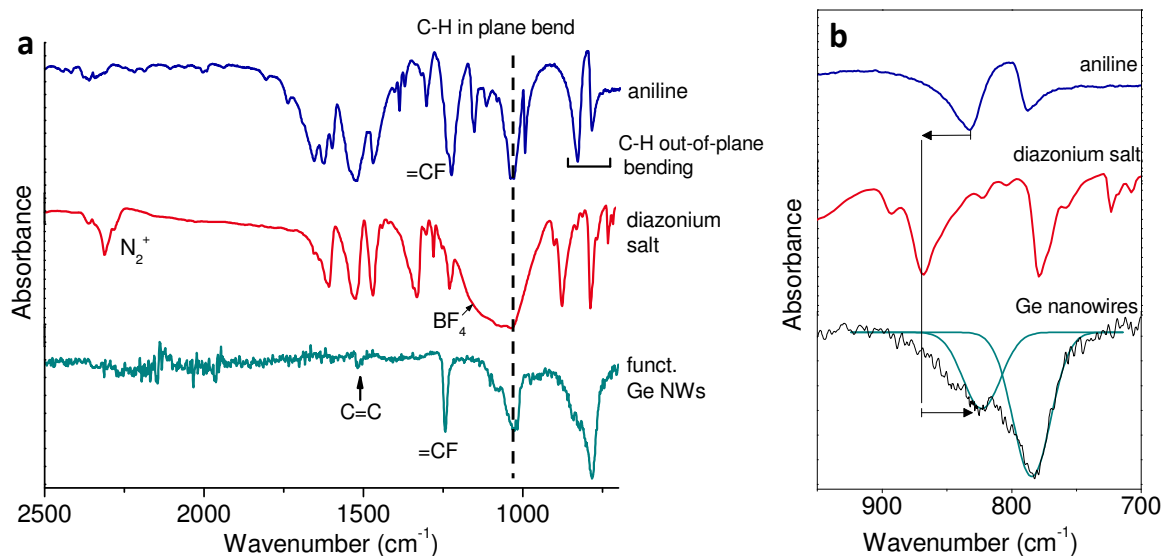


**Figure 5.** IR spectra of bulk diazonium salts and the ATR-IR spectra of Ge nanowires functionalized by (a) NO<sub>2</sub>Ph-BD and H-termination, (b) F<sub>17</sub>C<sub>8</sub>-BD.

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Figure 6(a) compares the IR spectra for the starting aniline, the diazonium salt and functionalized Ge nanowires. Similar to spectra shown in figure 5(a), the absence of vibrational bands attributed to the  $\text{N}_2^+$  and  $\text{BF}_4^-$  groups in the functionalized Ge nanowires suggest a reaction with the surface. The nanowire spectrum displays the presence of the =C-F absorption at  $1242\text{ cm}^{-1}$ , typical of aromatic fluorocarbons<sup>65</sup>, as well as the presence of the C=C stretching vibration at  $1518\text{ cm}^{-1}$ . Due to the high electronegativity of F substituents, the intensity of the C-H in-plane bending vibration is greatly enhanced and this can be seen in all of the spectra at  $1020\text{ cm}^{-1}$ <sup>66</sup>.

Reaction of the  $\text{F}_3\text{-BD}$  diazonium salt with the Ge surface can also be detected indirectly from its electronic impact on the C-H out-of-plane bending vibrations. The C-H bending vibrations are very informative about the nature of the substituents attached to the aromatic ring<sup>66</sup>. Figure 6(b) illustrates the C-H out-of-plane bending vibrations for the starting aniline, the diazonium salt and functionalized Ge nanowires. The aniline displays a C-H bend at  $832\text{ cm}^{-1}$  and after conversion into the diazonium salt the position of the vibration shifts to  $866\text{ cm}^{-1}$ . This shift to higher frequencies is consistent with the attachment of the highly electron-withdrawing  $\text{N}_2^+$  group<sup>63</sup>. After reaction with H-terminated Ge nanowires, the position of the C-H bend shifts back to a lower frequency ( $830\text{ cm}^{-1}$ ), as illustrated in figure 6(b), providing indirect evidence that the diazonium functionality is no longer associated with the ligand.



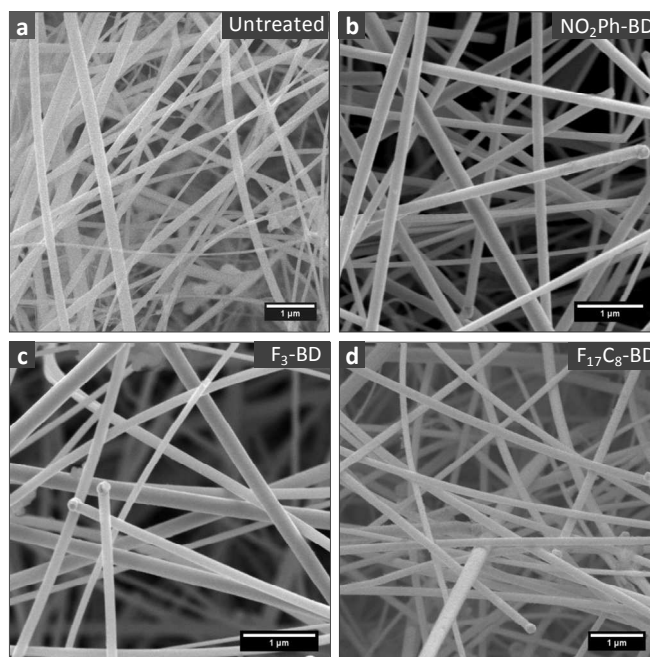
**Figure 6.** ATR-IR spectra of (a) trifluoroaniline, the corresponding diazonium salt (F<sub>3</sub>-BD) and functionalized Ge nanowires and (b) spectra illustrating the frequency shifts in the aromatic C-H out of plane bending modes.

### SEM and TEM of Surface Modified Ge Nanowires

Figures 7(a)-(c) display SEM images of Ge nanowires before and after treatment with arenediazonium salt solutions and shows that the functionalization procedure did not significantly affect the nanowire morphology. Figure 8(a) displays a TEM image of an untreated, oxidised Ge nanowire with a typical oxide thickness of 2-4 nm. Nanowires functionalized by immersion into NO<sub>2</sub>Ph-BD solutions for 2h and 12 h are compared in figures 8(b) and (c), respectively. A reaction time of 2 h yields a thin (1.5 – 2 nm) homogenous organic layer on the nanowire surface. After a 12 h reaction time, the thickness of the organic film increases to ~4 nm, accompanied by a slight decrease in uniformity relative to the thinner functionalization layer. TEM analysis suggests the presence of aryl multilayers, which form as a result of an aryl radical attaching to an already covalently bound ligand, as illustrated in figure 8(d). Diazonium ligands grafted electrochemically can yield

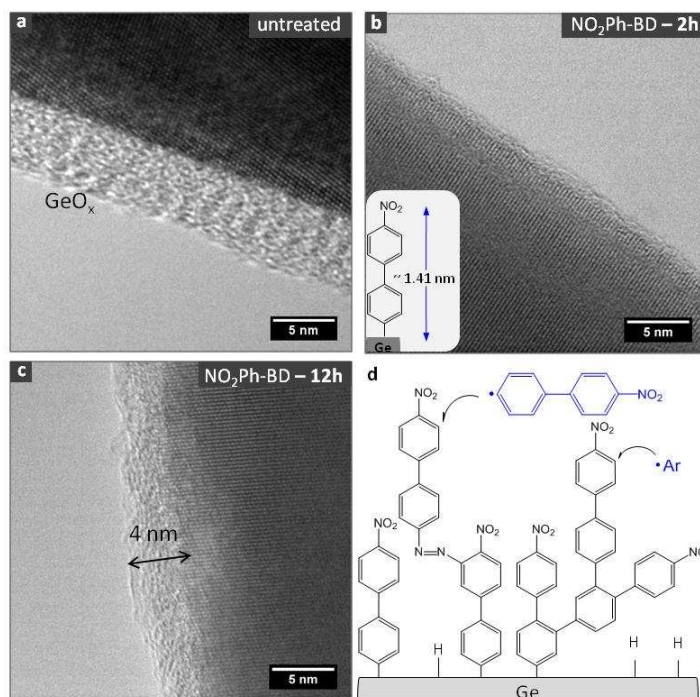


organic layers ranging from nanometer to micrometer thickness<sup>67-68</sup> and similarly, multilayer formation has also been reported with electroless surface modification<sup>44, 69</sup>.



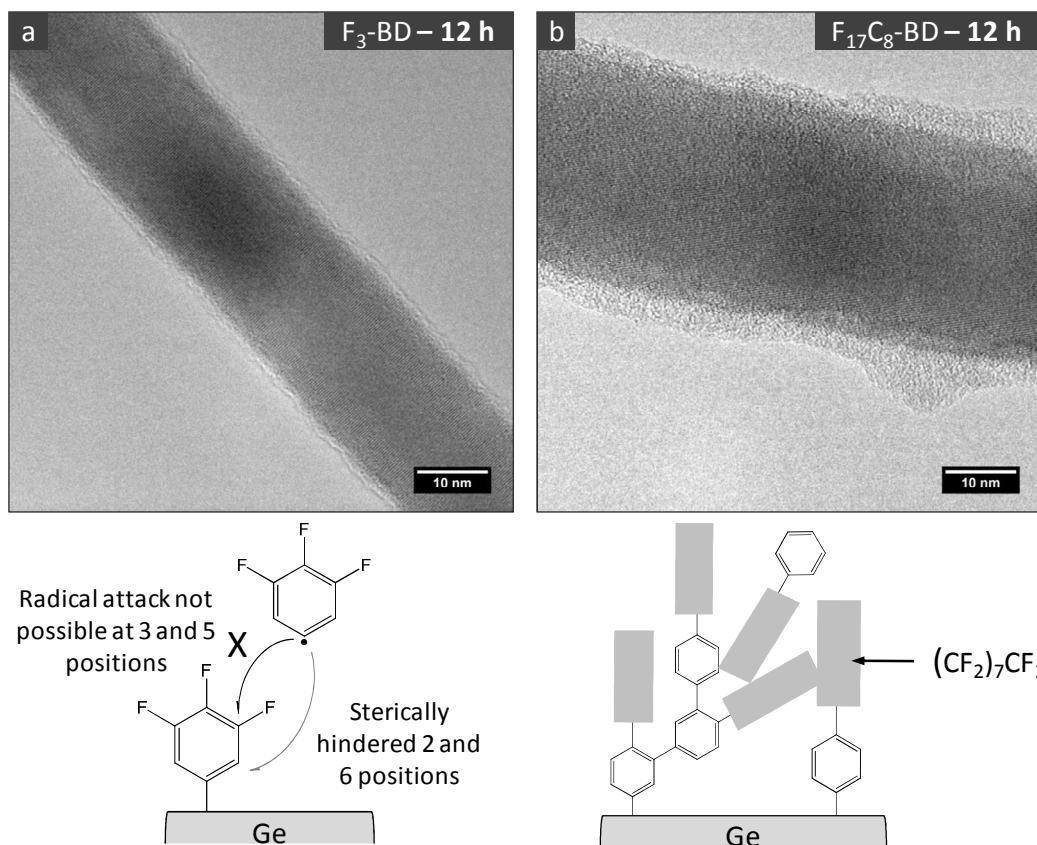
**Figure 7.** SEM images of (a) oxidised Ge nanowires and nanowires treated with acetonitrile solutions of (b) NO<sub>2</sub>Ph-BD, (c) F<sub>3</sub>-BD and (d) F<sub>17</sub>C<sub>8</sub>-BD.

The addition of aryl radicals to form multilayers proceeds preferentially via attack at the 3- and 5- ring positions (numbered relative to the diazonium group). A Ge nanowire modified with F<sub>3</sub>-BD, in which the 3-, 4- and 5- ring positions contain F substituents, is shown in figure 9(a). The influence of ring substituents on multilayer formation is apparent from the thickness of the functionalization layer; after a 12 h reaction time the organic layer remains thin (~ 1 nm) and does not undergo multilayer formation as observed with NO<sub>2</sub>Ph-BD. Side reactions with F<sub>3</sub>-BD can only proceed via radical attack on the 2- and 6- positions, which is disfavoured by steric constraints from the nanowire surface, as illustrated by the schematic shown in figure 9(a). Podvorica and co-workers<sup>70</sup> reported that electrografting of aryl ligands with bulky *t*-butyl substituents on the 3- and 5- ring positions producing ultrathin organic layers close to monolayer thickness, on Si surfaces.



**Figure 8.** TEM images of (a) non-functionalized Ge nanowire, (b) Ge nanowire functionalized with NO<sub>2</sub>Ph-BD after 2h reaction time, (c) NO<sub>2</sub>Ph-BD functionalized Ge nanowire after 12 h reaction time and (d) schematic illustrating the formation of aryl multilayers and possible introduction of azo species during multilayer formation<sup>45</sup>.

Figure 9(b) shows a TEM image of the functionalization layer obtained on Ge nanowires treated with F<sub>17</sub>C<sub>8</sub>-BD for 12 h. There is a large variation in the thickness of the functionalization layer along the length of the nanowire, ranging from ~2-10 nm. The poor uniformity of the organic layer can be attributed to the sterically bulky fluorocarbon segment attached to the aromatic ring, which disrupts the packing of the aryl layers as illustrated in figure 9(b).



**Figure 9.** TEM image of Ge nanowire modified with (a)  $F_3$ -BD, (b)  $F_{17}C_8$ -BD and schematics illustrating the influence of ring substituents on the formation of organic functionalization layers.

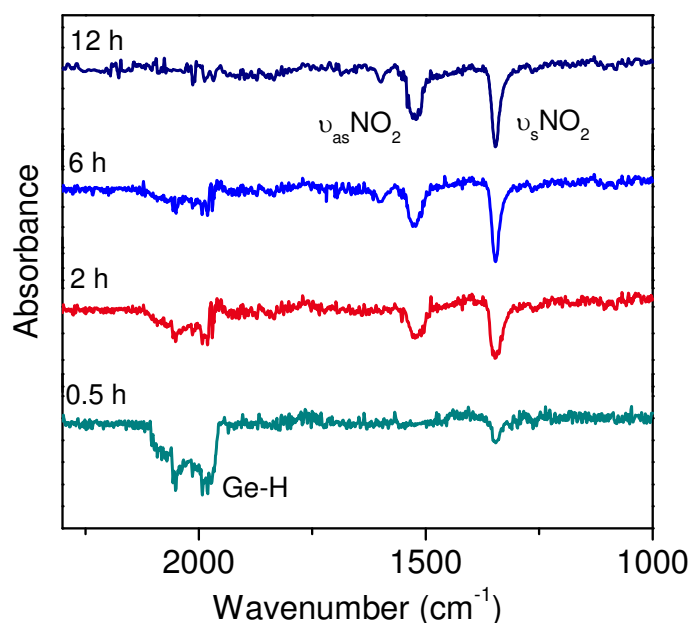
#### *Influence of the Reaction Time and Temperature*

Functionalization reactions were carried out at 50 °C and at room temperature to investigate if a spontaneous reaction with the H-Ge surface was possible. XPS analysis found that only one of the diazonium salts investigated in the study,  $F_{17}C_8$ -BD, underwent reaction with the H-Ge surface at ambient temperature (~25 °C). The relative amount of F present at 25 °C and 50 °C, obtained from the integral intensity of the Ge 3d: F 1s spectra was ~2.5 times smaller at room temperature compared to the nanowires functionalized at 50 °C (see Supporting Information), indicating that the reaction is less favorable at lower temperatures.

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3 Similarly, no N *1s* signal was detected for Ge nanowires treated with NO<sub>2</sub>Ph-BD at room  
4 temperature (figure S3). While both F<sub>3</sub>-BD and NO<sub>2</sub>Ph-BD did not display significant  
5 reaction with the Ge surface at room temperature, the reaction did proceed at 50 °C. The  
6 reduction potential of the diazonium moiety was dependent on the nature of the ring  
7 substituents; electron withdrawing substituents on the *para*-position increase the ease by  
8 which diazonium salts can be reduced<sup>71</sup>. Studies have shown that electrochemical reduction  
9 of diazonium salts containing electron withdrawing substituents occurs faster and at less  
10 negative reduction potentials, compared to salts containing electron donating substituents<sup>72</sup>.  
11 Fluorocarbons are electron withdrawing groups and the presence of a fluorocarbon chain  
12 located at the *para*-position should give rise to the easier reduction of the diazonium group  
13 and consequently result in reaction with the Ge surface at room temperature.  
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33 Haight and co-workers<sup>73</sup> observed that simply spraying a mist of diazonium salt/MeCN  
34 solution onto Si nanowires was adequate to achieve spontaneous surface functionalization,  
35 illustrating a very efficient reaction between the diazonium salt and the surfaces of the Si  
36 nanowires. The influence of the reaction time for Ge nanowire functionalization was  
37 investigated and figure 10 displays the IR spectra of nanowires treated with NO<sub>2</sub>Ph-BD at 50  
38 °C for 0.5, 2, 6 and 12 h. After 2 h an absorption peak attributed to the NO<sub>2</sub> stretching  
39 vibrations at 1345 and 1520 cm<sup>-1</sup> was observed. There was also a Ge-H vibrational stretch  
40 present as a broad peak in the range of 1990-2050 cm<sup>-1</sup>. After longer immersion times (6 h  
41 and 12 h), the intensity of the Ge-H vibrational stretch decreases. Both XPS and IR data  
42 indicated that reaction of diazonium salts on Ge nanowire surfaces required elevated  
43 temperatures and longer reaction times, relative to Si surfaces. Stewart *et al.*<sup>44</sup> suggested that  
44 the presence of a highly reactive Si-H surface may play a role in activating the diazonium  
45 reaction. Si(100) surfaces treated with aqueous HF solution are known to give rise to a  
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3 mainly dihydride terminated surface<sup>74</sup>, while Ge(100) surfaces tend to yield a more complex  
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5 mixture of mono- and dihydride species as well as small amounts of trihydride<sup>6</sup>, which may  
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7 influence the reactivity of diazonium salts towards the Ge surface. The IR spectra of H-  
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9 terminated Ge nanowires consists of a broad peak centred at  $\sim 2050\text{ cm}^{-1}$ , which is indicative  
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11 of the mono-, di- and trihydride species.  
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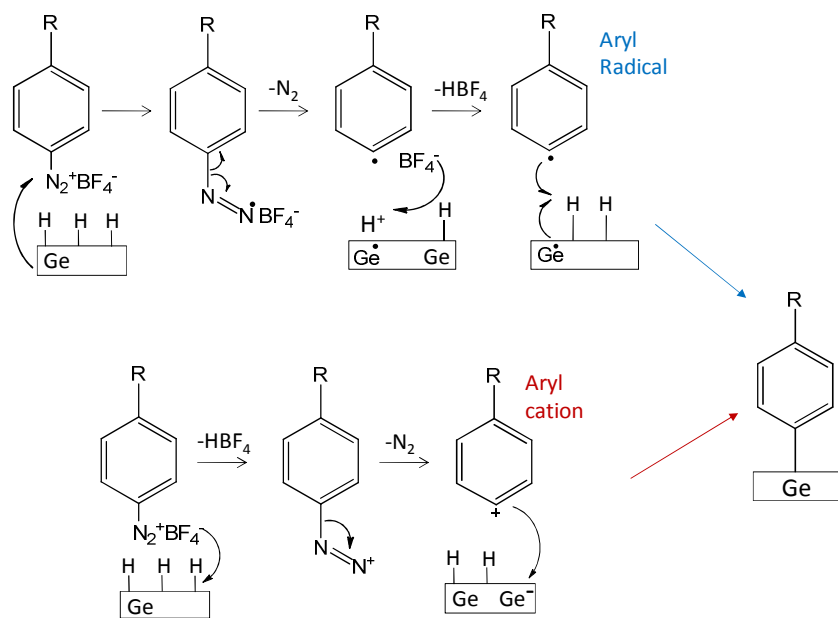


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38 **Figure 10.** ATR-IR spectra of H-terminated Ge nanowires immersed in NO<sub>2</sub>Ph-BD solutions  
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40 at 50 °C for 0.5 h, 2h, 6 h and 12 h.  
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#### 46 47 *Mechanism of Attachment*

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49 The synthetic utility of arenediazonium salts as precursors for surface functionalization is  
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51 based on the ease of reduction of the diazonium group. There are two possible reaction  
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53 mechanisms by which diazonium salts can react with the H-terminated Ge surface and are  
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55 illustrated in figure 11. The first is heterolytic dediazonation producing an aryl cation, a  
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57 mechanism which involves hydrogen abstraction from the H-Ge surface<sup>53</sup>. However,  
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59 germanes have a greater H-donor ability than silanes<sup>75</sup> and so a hydrogen-abstraction  
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mechanism would imply that the reaction would proceed faster on a H-Ge surface than on a H-Si surface, which was not the case observed here. Furthermore, organo silyl ( $R_3Si-H$ ) and stannyls ( $R_3Sn-H$ ) hydrides do not react with diazonium salts via hydride abstraction and it is likely that germlyl hydrides also exhibit this trend in reactivity<sup>76</sup>.



**Figure 11.** Reaction scheme outlining two possible reaction mechanisms for the covalent attachment of aryl ligands to H-terminated Ge nanowires based on the formation of an aryl radical or aryl cation<sup>48</sup>.

The second possible reaction mechanism involves homolytic dediazonation. This reaction pathway involves electron transfer from the Ge surface (or possible trace impurities) to the arenediazonium salt forming an aryldiazenyl radical, which then loses  $N_2$  to yield an aryl radical<sup>53</sup>. Stewart and co-workers<sup>44</sup> provided evidence for this mechanism by observing that the introduction of a radical scavenger reduced the thickness of the functionalization layers on semiconductor surfaces. Wang and Buriak<sup>77</sup> conducted radical trapping experiments and showed the spontaneous electron reduction of diazonium salts in the presence of H-

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3 terminated planar and porous Si, produces surface Si radicals. A radical mechanism would  
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5 be more favorable at a H-terminated Si surface than a H-terminated Ge surface due to the  
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7 greater polarization of the Si-H bond <sup>24, 78</sup>, which may account for the lower reactivity  
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9 observed at Ge surfaces. Furthermore, a homolytic dediazonation mechanism is consistent  
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11 with our observation that only F<sub>17</sub>C<sub>8</sub>-BD, underwent spontaneous reaction with the H-Ge  
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13 surface. The formation of aryl radicals is favored by the presence of electron withdrawing  
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15 substituents at the *para*-position, as is the case with the fluorocarbon chain in F<sub>17</sub>C<sub>8</sub>-BD<sup>79</sup>.  
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18 TEM analysis indicates the presence of thin aryl multilayers and this observation is  
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20 suggestive of a radical mechanism<sup>72, 80</sup>.  
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29 While a radical mechanism similar to that observed for Si surfaces may be responsible for the  
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31 spontaneous grafting to Ge nanowires, heating of the diazonium salts solutions was required  
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33 to induce grafting of NO<sub>2</sub>Ph-BD and F<sub>3</sub>-BD ligands and so thermal initiation clearly plays a  
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35 role in the functionalization procedure. Thermal decomposition of arenediazonium salts can  
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37 proceed through the formation of aryl radicals or cations and many factors such as solvent  
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39 polarity, ring substituents and the reaction atmosphere (N<sub>2</sub> versus O<sub>2</sub>), are known to influence  
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41 the mechanistic pathway and the reaction products<sup>81</sup>. While further studies are required to  
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43 fully elucidate the mechanism, a combination of thermally induced dediazonation in  
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45 solution, the presence of a highly reactive Ge-H surface and possibly the presence of trace  
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47 impurities from the nanowire synthesis may all contribute to the covalent grafting of aryl  
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49 ligands on Ge nanowire surfaces.  
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## Conclusions

Organic surface functionalization of Ge nanowires using diazonium salts was investigated. XPS and ATR-FTIR results indicate that functionalization of H-terminated Ge nanowire surfaces is possible through the decomposition of arenediazonium salts in MeCN solutions. XPS and ATIR analysis clearly identifies the spectral signatures of the functionalization ligands on the Ge nanowires while also indicating the loss of the  $\text{N}_2^+$  and  $\text{BF}_4^-$  functional groups. The nature of the ring substituents was found to influence the structure of the organic functionalization layer obtained on the Ge nanowires. For mono-substituted arenediazonium salts the thickness of the organic layer increases with reaction time due to the formation of aryl multilayers. Highly substituted aromatic rings however, resulted in thin functionalization layers as multilayer formation is hindered. Furthermore, sterically crowded ring substituents produce poorly uniform functionalization layers. The results here illustrate the potential of arenediazonium salts as precursors for the functionalization of Ge nanowires, which may allow for the controlled growth of multilayer thin films or organic monolayers on the nanowire surface.

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